

Probe Software

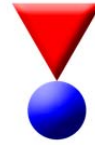
Software for MicroAnalysis

Probe for EPMA

Probe Image

PictureSnapApp

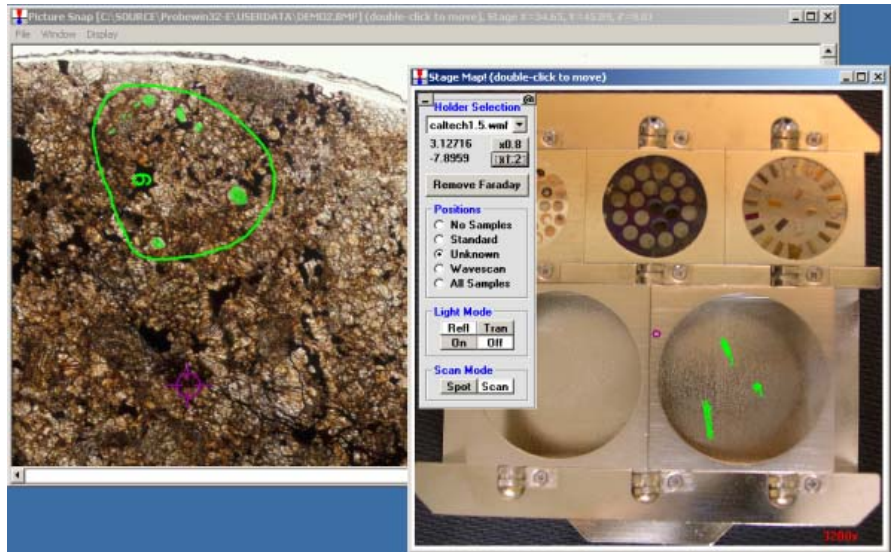
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Probe for EPMA: Software for Electron Probe MicroAnalysis

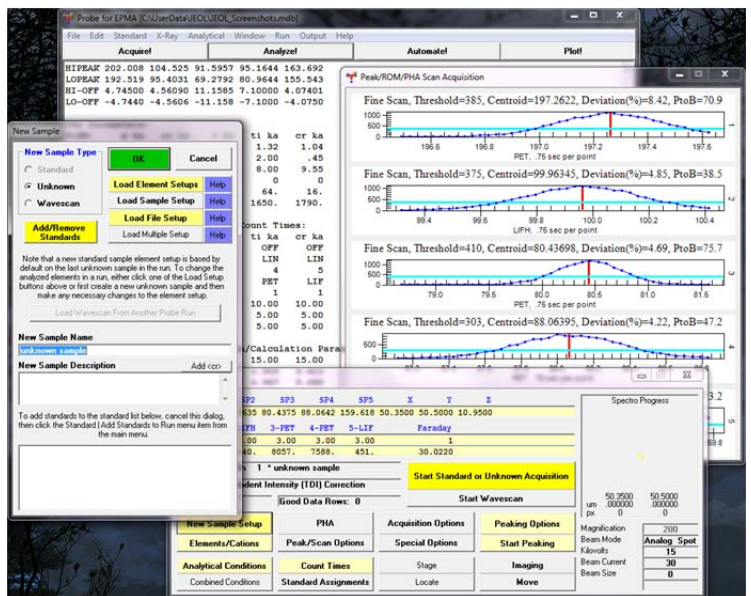
- Navigate your sample graphically using the StageMap and PictureSnap click and go features!

- User definable stage maps using drawings or scans.
- Easy importing for optical sample scans.
- Two or three point stage calibrations.
- Automatically corrects for sample rotation and tilt.
- Live current position cursor.
- Live scan size display based actual magnification.
- Display digitized standard and unknown coordinates.
- Display previously acquired data points.
- Save, export or print annotated images.



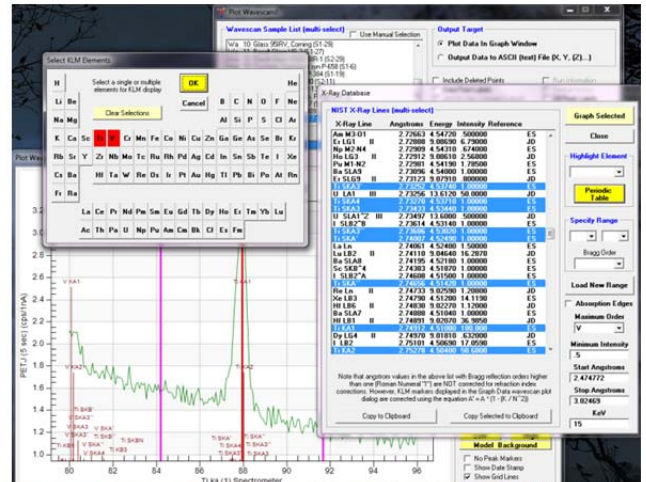
- Create and acquire integrated unknowns, standards and wavescans with two mouse clicks!

- One application acquires, analyzes and outputs all sample types.
- Load previously configured sample setups and easily modify.
- Import prior standardizations and easily update if necessary.
- One button update of peak positions and PHA settings.
- All peaking scans and PHA scans automatically saved.
- User definable dwell time and scan density for peak centering.
- Browsable element setup database with search capability.
- Choice of parabolic, maxima and gaussian peak fitting.
- Automatic acquisition of all element ROI scans for off-peaks.



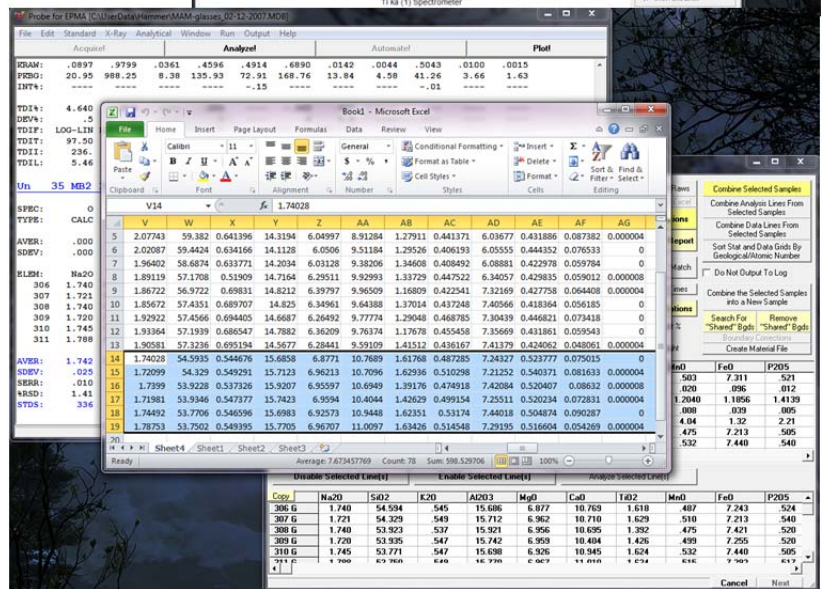
- Check for interferences automatically and adjust off-peak positions graphically!

- Easily model, confirm and specify spectral interferences.
- Specify up to 5 interfering elements per element.
- Define KLM markers based on analytical or arbitrary selection.
- Specify off-peak positions with a single mouse click.
- Changes to off-peak positions are automatically saved.
- Extensive modeling of background fitting options.
- One mouse click to apply new models to any or all samples.



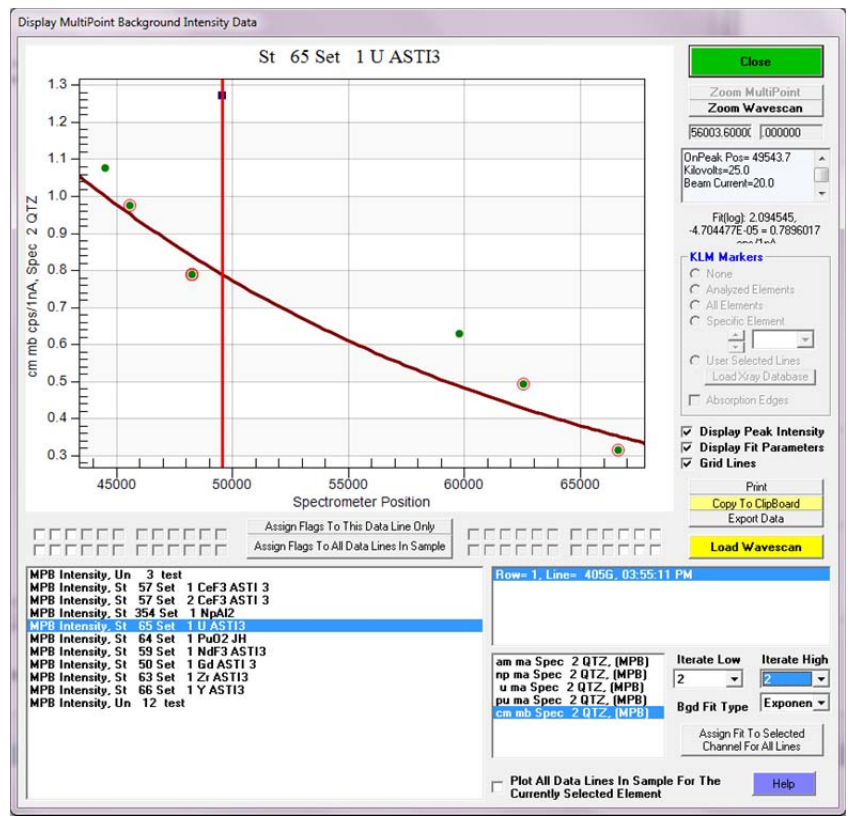
- Output any or all data and calculations to plots or Excel spreadsheets!

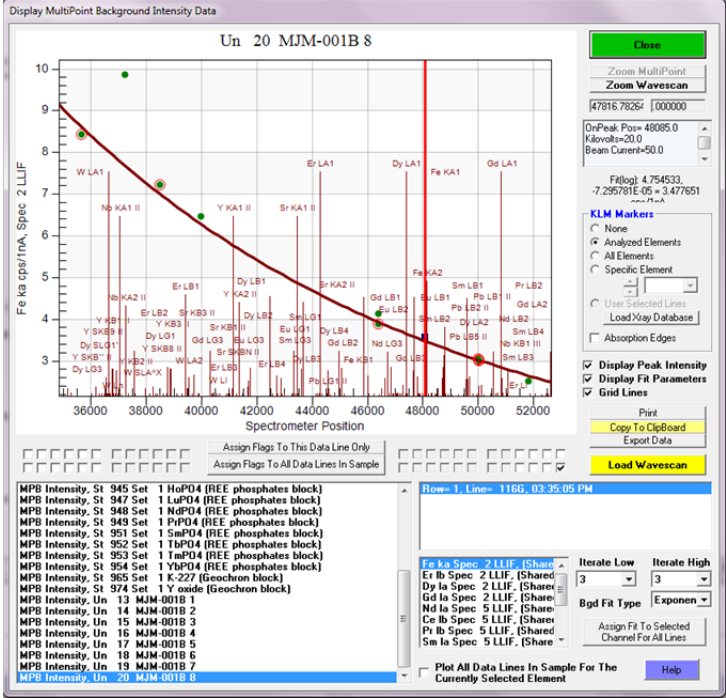
- Manual or automatic linking to Excel spreadsheets.
- Export standard, unknown or wavescan data to Excel.
- Display analytical data in column or row format.
- Use pre-defined, manually selected or custom output formats.
- Export thin film and raw data formats.
- Automatically plot all data for reports.
- Export to tab delimited text or copy to clipboard.
- Export all data types: images, EDS, peaking, PHA, etc.



- Utilize the state of the art background corrections with multi-point and “shared” backgrounds!

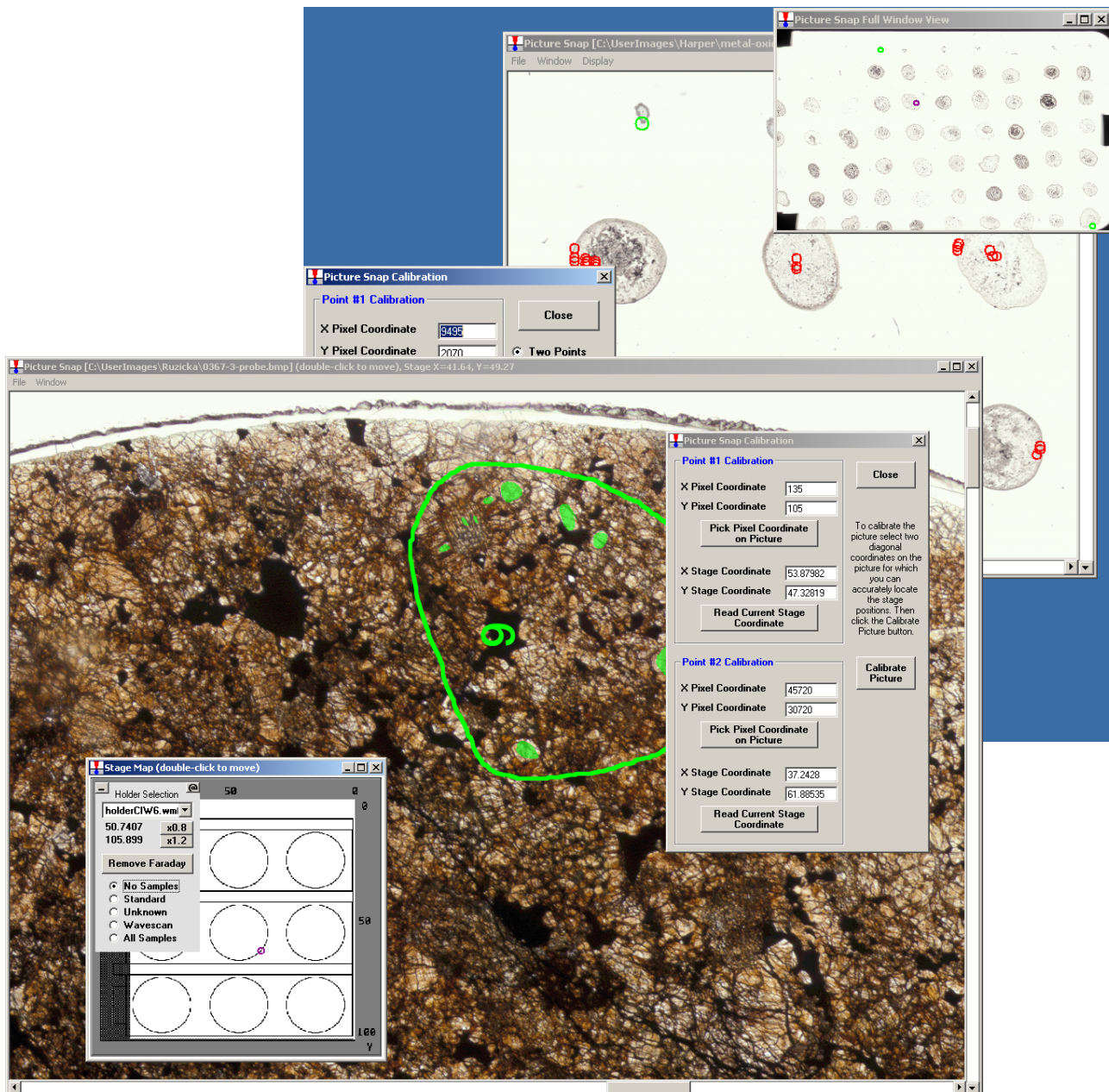
- Utilize up to 12 off-peak background positions on each side of the peak.
- Or “share” background positions from other elements which were acquired using the same spectrometer and crystal.
- Perform graphical analysis of your backgrounds using linear, polynomial and exponential fitting methods.
- Perform all these procedures during on-line acquisition or in off-line post processing.





1. New PictureSnap! Easy Sample Navigation Feature

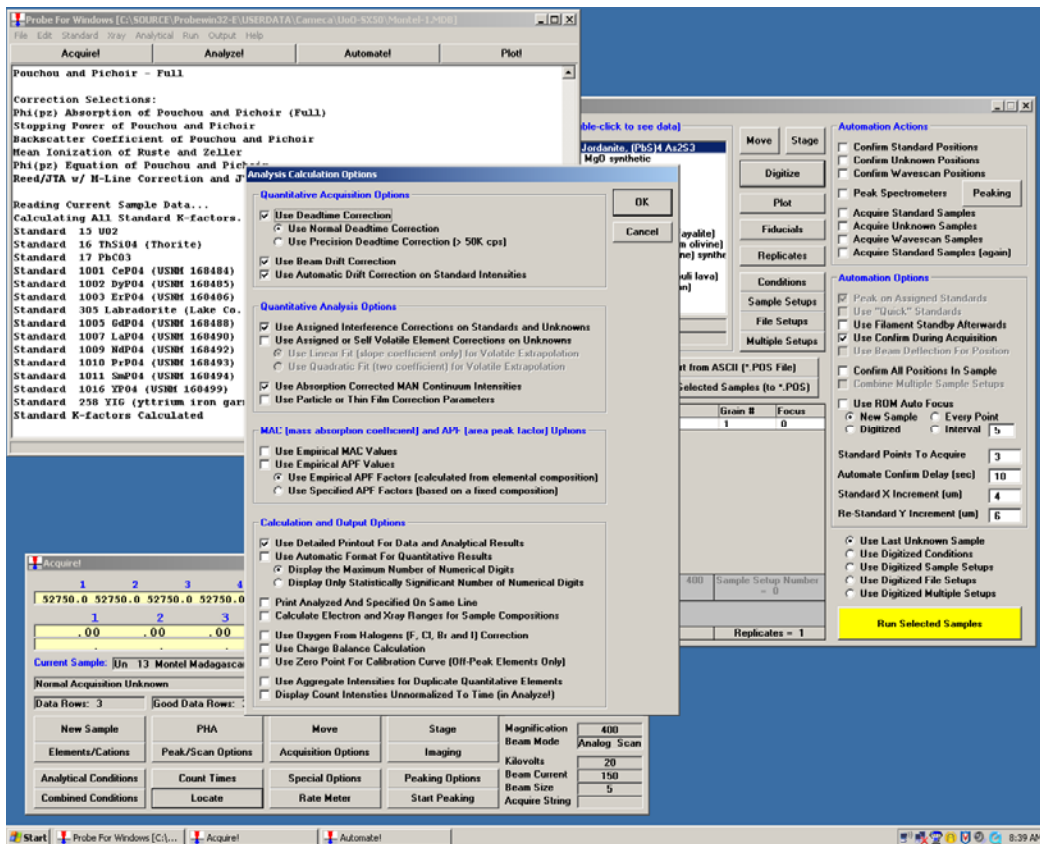
- Import any image from any slide or flat bed scanner and quickly calibrate the image to your stage coordinates with two mouse clicks (three clicks for round samples)!
- Navigate the sample by simply clicking on the sample position!
- See where you are at all times using the live stage cursor!
- Display analyzed sample coordinates and point and line number labels directly on the image!
- Print or save to file or clipboard a high resolution optical image showing where your analyzed positions are located- directly on the sample!



A cool feature that makes it easy to digitize, acquire and display analytical data, even on complicated and fine grained samples!

1. Native TCP/IP Support for Cameca SX100 and JEOL 8900/8200/8500

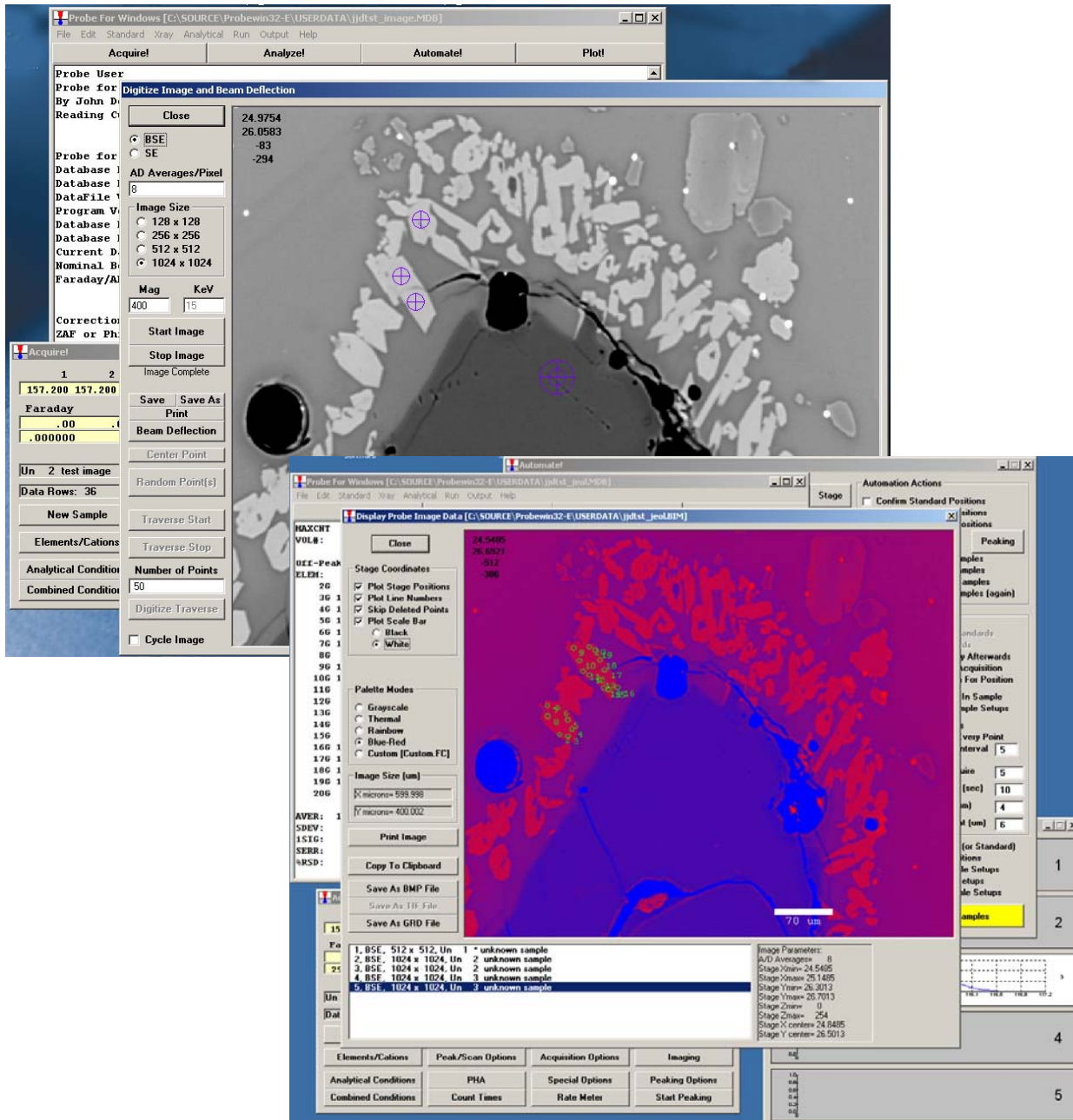
- Allows both Probe for EPMA and OEM software to be connected simultaneously to the SX100 and 8900/8200/8500 without re-configuration or re-connection. Now you can have the powerful PROBE algorithms running on your new JEOL or Cameca instrument!
- Allows maximum flexibility for acquisition, automation and analysis. Remember, Probe for EPMA has an unlimited redistribution license for off-line processing! Everyone who acquires data with your instrument can have a copy for off-line analysis of their data.
- Now with NIST's latest FFAST (Chantler-2005) mass absorption coefficients for best accuracy!
- Utilize PROBE for EPMA's unique, easy to use and automatically iterated truly quantitative interference correction!
- Utilize PROBE for EPMA's easy to use graphical volatile element and alternating background acquisition!
- Utilize PROBE for EPMA's unique statistical output feature to only display statistically significant data and digits!
- Utilize PROBE for EPMA's unique high accuracy halogen matrix correction for dealing with oxygen equivalent of halogens when calculating oxygen by stoichiometry and much more!



No instrument hardware or network configuration changes are required to run Probe for EPMA. Simply add a PC, install the software and connect a network cable to your existing hub!

2. Fast and Easy Integrated Analog Imaging

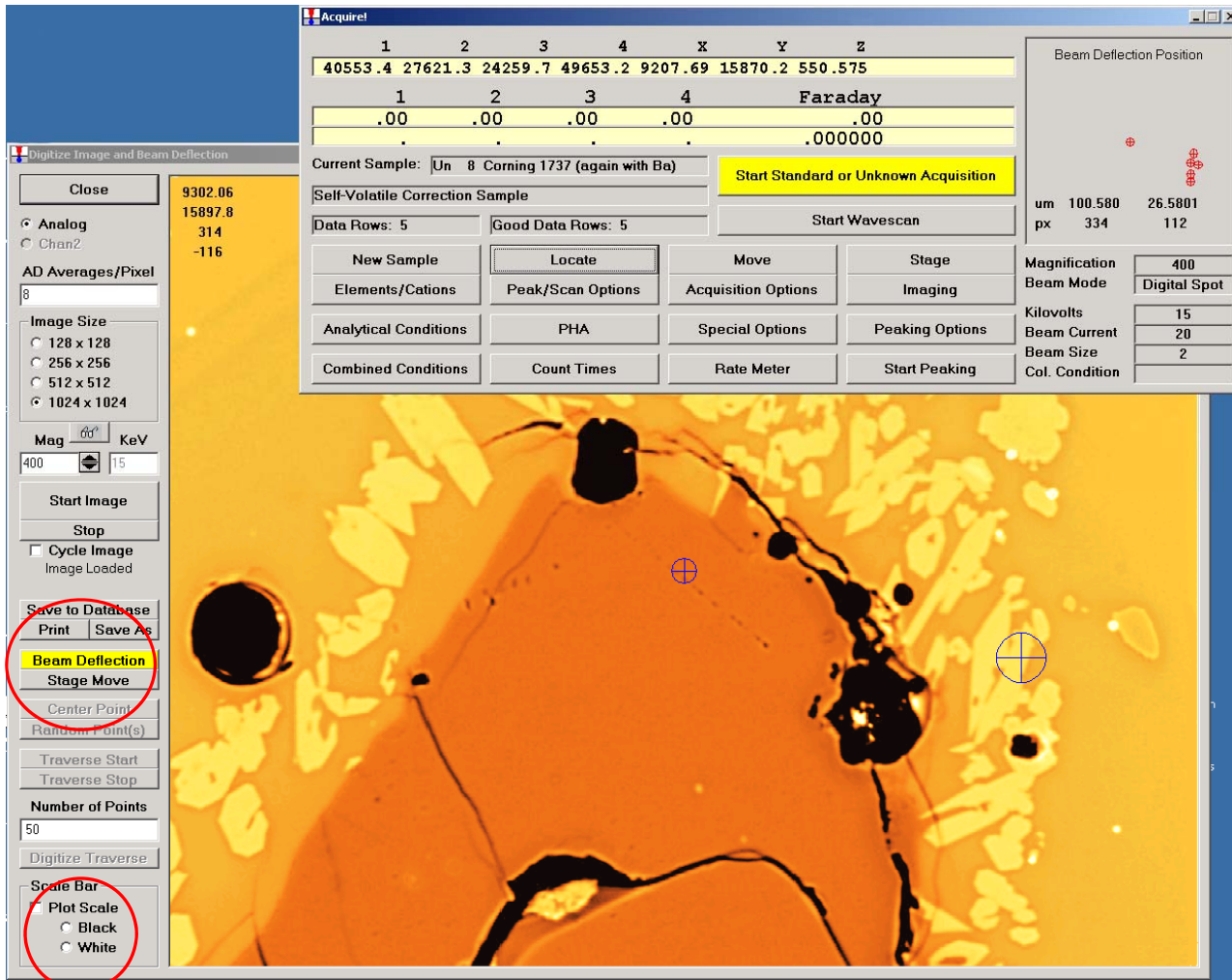
- Both manual and automated image acquisition modes on standards, unknowns and wavescans.
- Images are tagged to analytical samples.
- Analytical position coordinates are plotted on image overlay.
- Standard and user defined display palettes (LUT).
- Integrated scale bar in black or white.
- Enhanced image digitizing of coordinates for stage or beam deflection acquisition.



Fully integrated manual and automated analog imaging for precise beam control, digitizing and documentation of sample analyses.

3. Realtime Beam Deflection and Column Condition Display

- Graphical display of current beam deflection position (manual and automated).
- Realtime display of current column conditions and beam scan modes.
- Realtime display of user defined acquisition macro-commands.



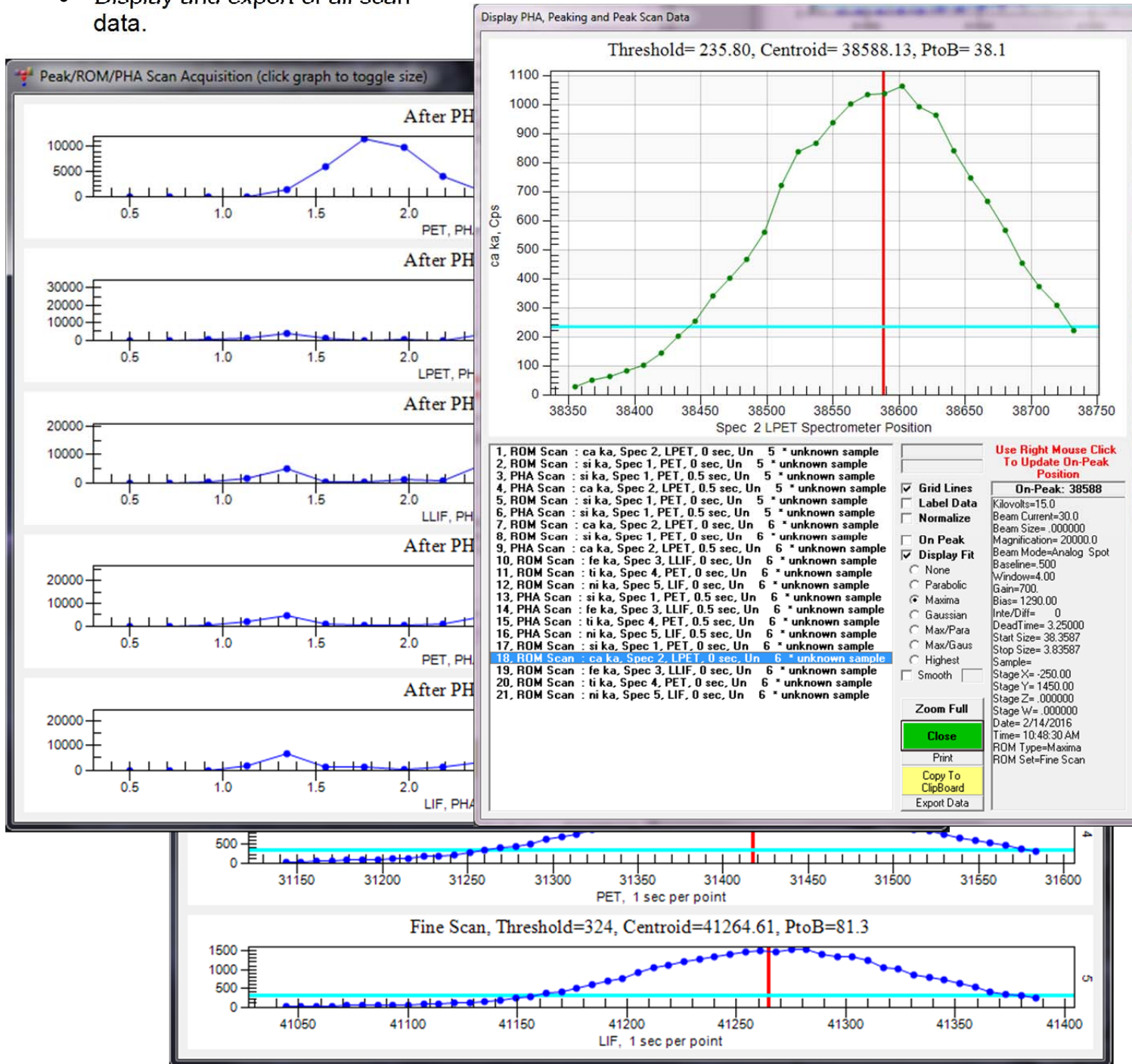
Observe a graphical display of your beam deflection coordinates in microns and pixel units for both manual and automated beam deflection acquisitions.

Use the graphical stage move to re-center the beam and move the stage to the exact sample position based on the displayed image.

Live mouse cursor for instant stage coordinate readout.

4. Automatic Recording of Scan Data

- Automatically acquire and save all PHA, bias and gain detector scans.
- Automatically acquire and save all ROM peaking and pre and post peak scans.
- Display and export of all scan data.

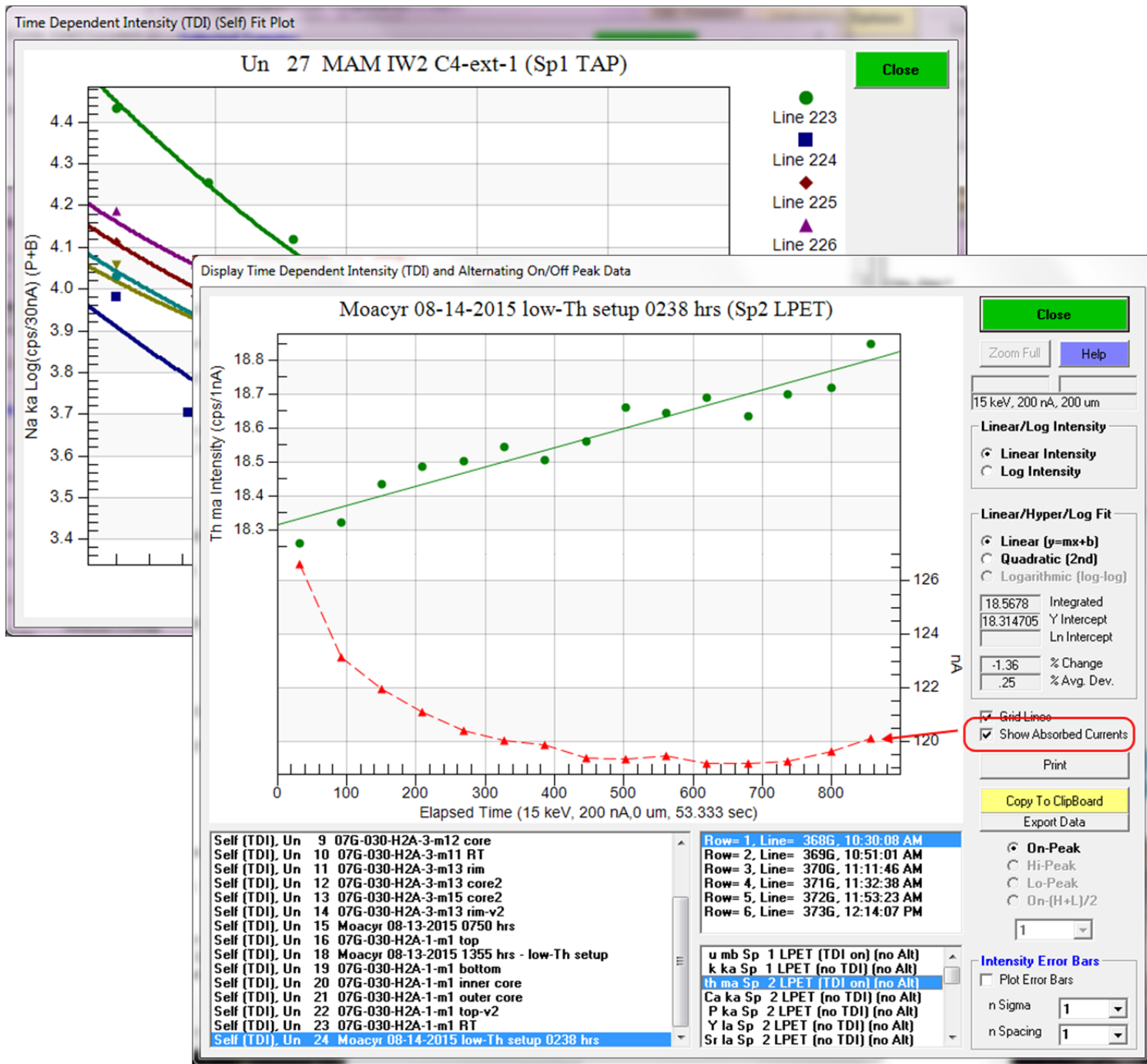


Have a complete and permanent record of all instrument calibrations including PHA and peaking procedures and intensity data in each user database.

All scans including ROM peak scans are tagged to the specific data file samples for accurate referencing of instrument adjustments.

5. Automatic Recording of Volatile and Alternating On/Off Peak Intensities

- Automatically record all volatile calibration intensities.
- Automatically record both on and off-peak (alternating) intensity data.
- New high accuracy (quadratic exponential) fit for large volatile loss or gain.
- Display and export to ASCII file for external re-processing and plotting.



Easily correct for sensitive samples by automatic acquisition and correction for intensity changes over time by correcting for both intensity loss or gain.

For extended acquisition time on trace elements, use the alternating on and off peak acquisition to integrate the peak and background intensities repeatedly and monitor long term trends in intensity changes.

6. Enhanced Wavescan Display Plotting

- Resizable plot window for clear readability.
- Display up to XX (20th) order lines (new NIST x-ray database).
- Spin buttons for fast graph zoom and pan.
- Improved KLM peak labels.



Plot wavescan intensities and select off-peak positions with two mouse clicks on the graph control. Changes are automatically recorded to your user database.

7. Row and Column Display of Analytical Results and Match Capability

- Display both element column and elements row display formats at the same time with all specified data types.
- See all results, elemental, oxide, atomic, formula, intensity in one easy to read format.
- Copy to clipboard and paste into any document or report.
- Match unknown compositions to complete mineral, NIST and other databases.

The screenshot displays the Analyze! software interface with several windows open. The main window shows a sample list and analytical results. A 'Results Based on Sum of 2 Cations' window is visible, showing a table of elemental and oxide data. A 'Standards Found' dialog box is open, listing various mineral standards and their compositions.

Sample List (multi-select) (double-click to see intensity data)

- Standards: Un 1 * monazite setup
- Unknowns: Un 2 detection limits on LaPO4
- Wavescans: Un 3 GSC-4170.gr5
- All Samples: Un 4 * GSC-4170 gr5, Un 5 * unknown sample2

Specified Concentrations

Un 3 GSC-4170 gr5	26.957	Total Oxygen	100.675	Total Weight %
TO = 40, KeV = 20, Beam = 150, Size = 5	26.957	Calculated Oxygen	41.880	Z - Bar
	.000	Excess Oxygen	39.808	Atomic Weight

Results Based on Sum of 2 Cations

Copy	Ca	Si	Al	Y	Pr	Nd	Sm	Gd
Average:	.047	.073	.000	.009	.044	.154	.022	.011
Std Dev:	.003	.011						
ZAF Corr:	1.0599	1.980						
Std Err:	.001	.004						
%Rel SD:	5.9	13.1						
Minimum:	.045	.062						
Maximum:	.052	.082						

Standards Found (double-click to see composition data)

Copy	Na2O	SiO2	K
469 G	1.201	51.508	
470 G	.765	51.520	
471 G	.704	50.875	
472 G	.701	51.060	

Standards Found List:

- v = 3.93 2053 Chromian augite, gabbro, p. 1
- v = 4.45 2051 Chrome diopside, S. Africa
- v = 5.44 2072 Pargasite, Finland, p. 152
- v = 8.48 2070 Hornblende, India, p. 151
- v = 11.31 2094 Talc, northern Sweden, p. 1
- v = 11.56 2074 Basaltic hornblende, Color
- v = 11.93 2770 Harvaard 0- Kaersutite 1310
- v = 12.31 2071 Hornblende, tonalite, Idah
- v = 12.31 2075 Kaersutite, p. 152
- v = 12.37 2079 Richterite, Sweden, p. 153
- v = 12.61 2080 Magnesiokataphorite, Monta
- v = 13.26 2134 Labradorite, Millard Co.,
- v = 13.39 2037 Clear vitreous beryl, p. 8
- v = 13.59 2168 Laumontite, Saale, Germany

Display all results (k-ratios, intensities, elemental, oxide, atomic and formula), and quickly drill down for more detail with a simple double-click of the mouse.

8. Improved PHA Scanning is Automatically Saved To User's Database

- Realtime display of all PHA acquisition data in user database.
- Now scan both bias ranges and gain ranges .
- Export of PHA acquisition data to ASCII file.
- Automated PHA scanning of all spectrometers (Startwin utility).
- Automated PHA scanning before and/or after manual or auto peaking procedures.

The screenshot displays three overlapping software windows from a Pulse Height Analysis (PHA) system.

Move Motors and Crystals: This window is used for adjusting the physical components of the detector. It includes sections for 'Stage Target Positions' (with X, Y, Z, W coordinates and an increment of .02435) and 'Spectrometer Target Positions' (with SP1-SP5 settings for various elements like PET, LIF, TAP, and LiF). It also features 'Jog Stage', 'Park Stage', 'Jog Spectrometers', and 'Park Spec' buttons.

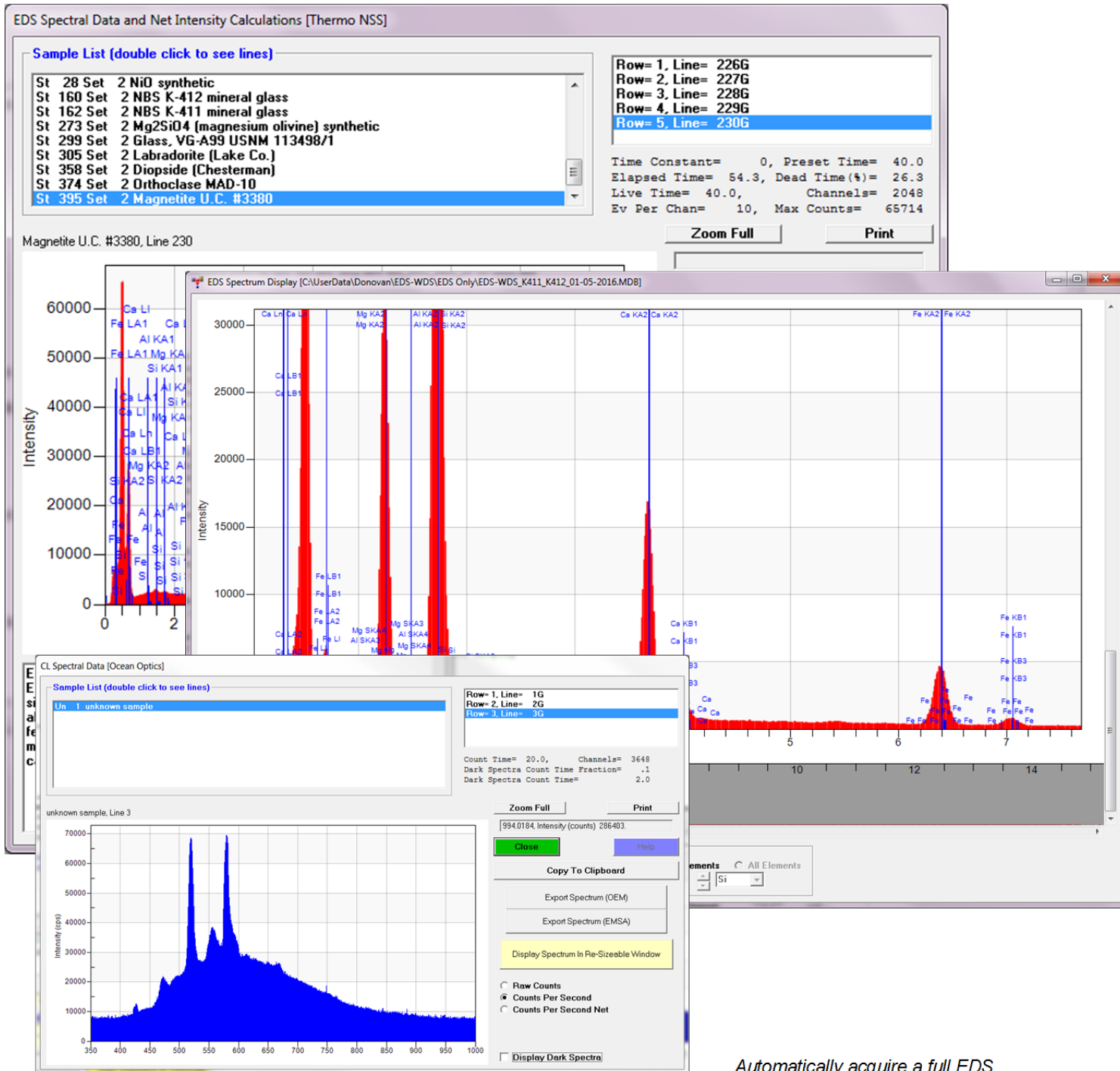
PHA Properties: This window allows for setting specific parameters for a scan. It includes fields for 'Baseline' (4.5), 'Window' (9.55), 'Gain' (16.00), and 'Bias' (1790). It also has options for 'Integral/Differential' (Use Differential checked) and 'Deadtime' (1.00). A graph at the bottom shows a pulse height distribution with 'Baseline Volt' on the x-axis (0 to 6) and counts on the y-axis (900 to 1100).

Pulse Height Analysis (PHA) Parameters: This is the main configuration window. It contains a table for defining spectrometer parameters for 9 different spectrometers (SP1-SP9). The table includes columns for BaseLine, Window, Gain, Bias, Inte/Diff, and Deadtime. Below this is a section for 'Scan Bias or Gain' with columns for Bias Low, Bias High, Gain Low, Gain High, Scan BaseL, and Scan Wind. At the bottom, there are 'Detector Parameters' for Slit Size, Slit Position, and Det. Mode for each of the 9 spectrometers. The window also includes buttons for 'OK', 'Close', 'Load PHA Parameters From PFW Database', 'Automatically Adjust PHA', 'Scan PHA', 'Count Time', 'Intervals', 'Acquire and Graph PHA Distribution', 'Acquire and Graph Bias Scan Distribution', 'Acquire and Graph Bias Scan Distribution', 'Count Time', 'Intervals', 'Acquire and Graph Bias Scan Distribution', 'Set PHA', and 'Get PHA'.

Acquire PHA, bias and gain distributions with real time display and automatically save to your user database for complete documentation of instrument conditions.

9. Improved EDS (and CL) Spectral Acquisition and Processing Interface

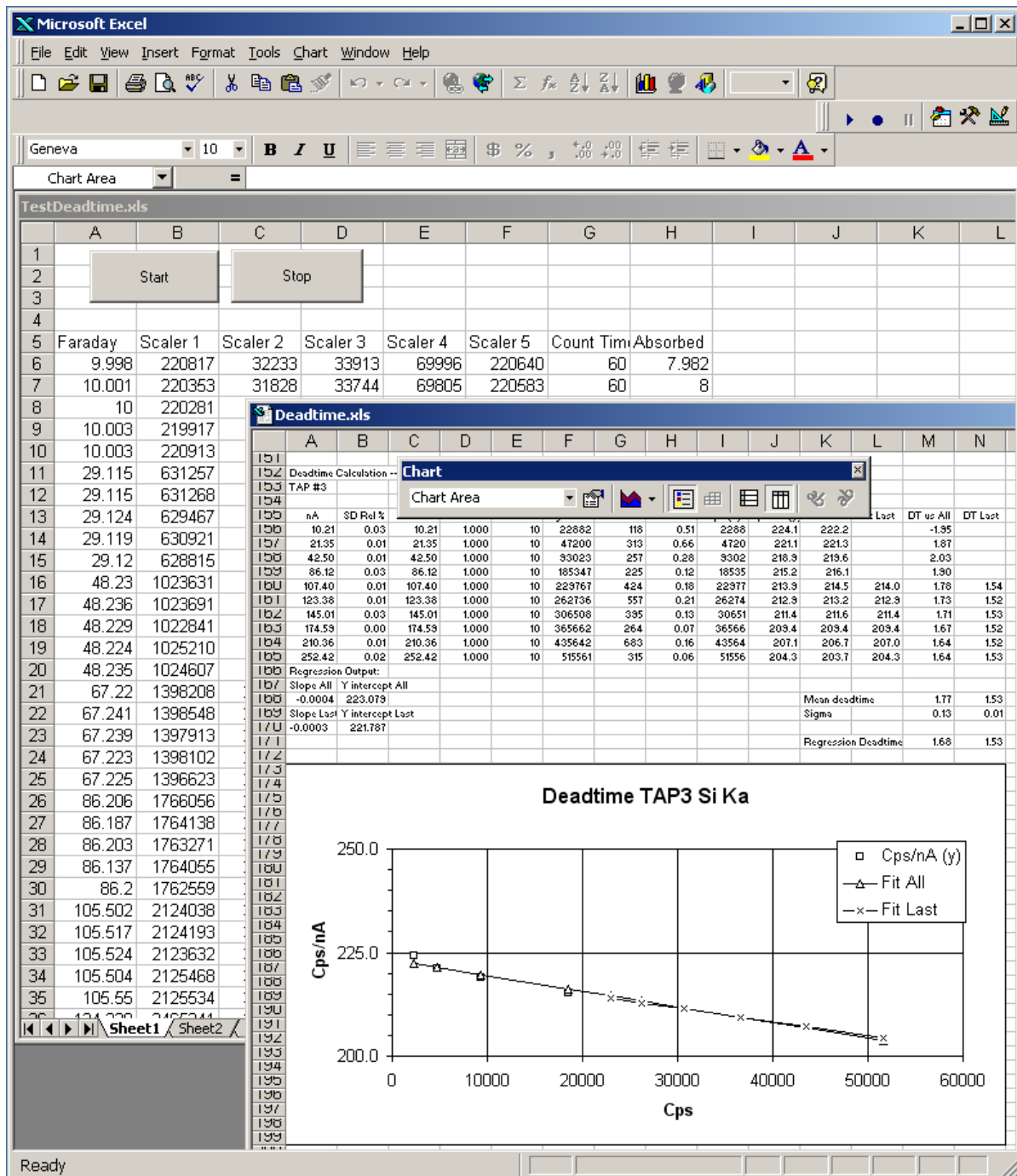
- Supports Thermo, Edax, Oxford and Rontec EDS interfaces
- User definable EDS integration time and EDS application preset time.
- Automatically acquire a full EDS spectrum for each analysis.
- Easily integrate WDS and EDS elements using self-consistent matrix corrections.



Automatically acquire a full EDS spectrum and all necessary detector parameters for complete off-line re-processing of combined EDS/WDS data.

10. Enhanced Excel Remote Automation Interface

- Operate your electron microprobe from Excel!
- Write custom macros for your specific acquisition or test procedures
- Control all instrument parameters (stage, spectrometers, crystal flipping, counting, column, etc) in a device independent fashion.



Automatically calibrate instrument deadtime and detector response curves with supplied Excel macros (written by Paul Carpenter) and modify or design your own!

11. Enhanced Elapsed Time Predictions

- Shows elapsed time on an element basis for each spectrometer.
- Color coded by x-ray line (R=Ka, G=La, B=Ma) and current crystal.
- Standard, Unknown and Wavescan acquisition times calculated separately.
- Calculate appropriate off-peak integration time statistics for optimum acquisition.
- Show remaining time for automated acquisitions.

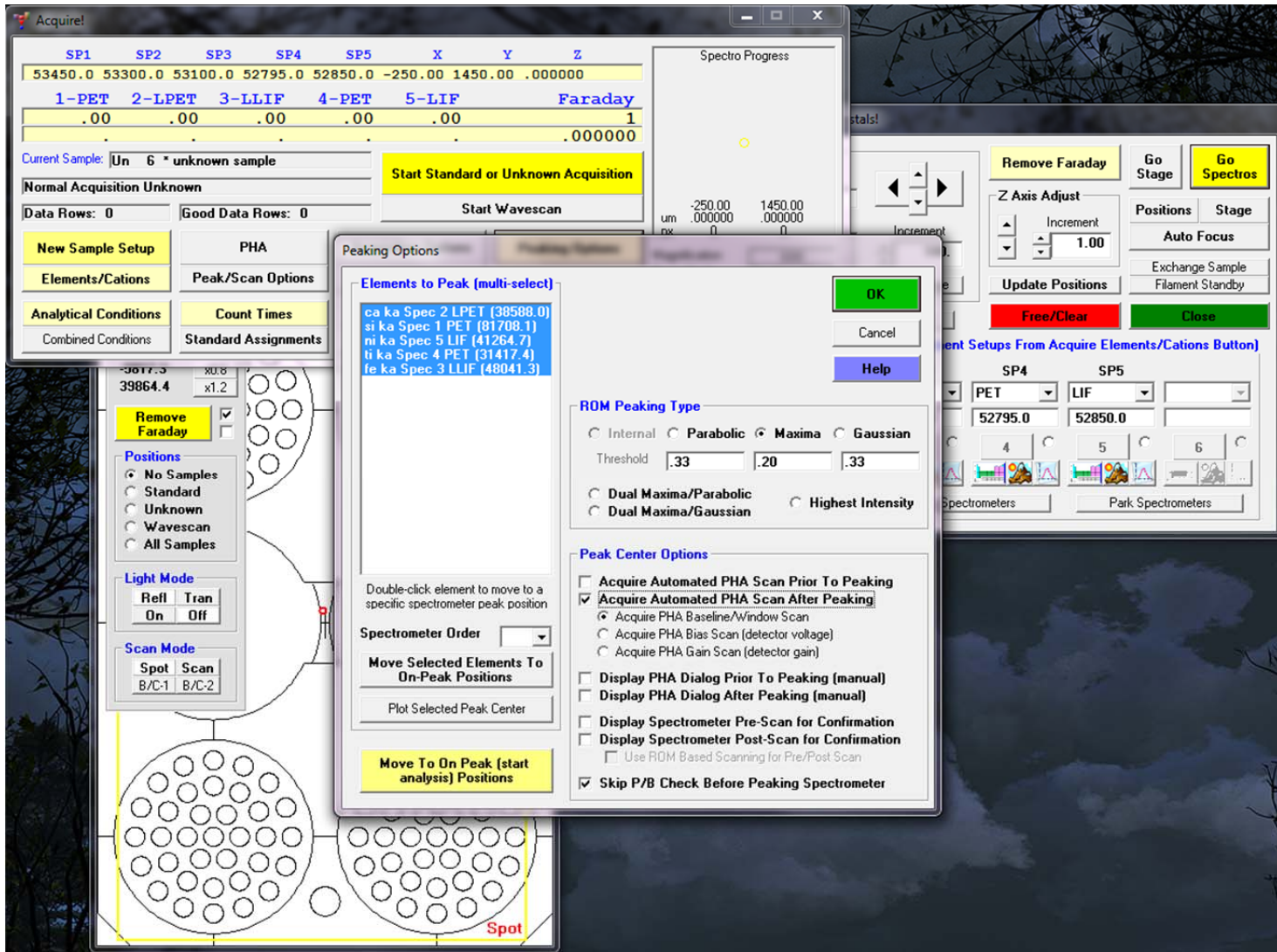
The screenshot displays the 'Acquire!' software interface with several key components:

- Top Panel:** Shows acquisition parameters for spectrometers SP1 through SP5 and X, Y, Z. Values include 157.200, 157.200, 145.365, 157.200, 157.200, 24.8500, 26.5000, and 11.2000. A 'Faraday' section shows values like .00, .00, 8.00, .00, .00.
- Current Sample:** 'Un 14 * Montel Madagascar 6-1'. A yellow button 'Start Standard or Unknown Acquisition' is visible.
- Count Times Table:** A table with columns: Channel, Element, Spectro, Crystal, On-Peak, Hi-Peak, Lo-Peak, MaxCount, Factor, Wave, Peak, Quick. It lists elements like ca ka, si ka, al ka, y la, pr la, nd la, sm la, gd la, ce la, la la.
- Count Time Properties Dialog:** A dialog for 'sm la' with fields for On-Peak Time (240.000), Hi-Peak Time (15.8161), Lo-Peak Time (15.8161), Wave Scan Time (2.00), Peaking Time (8.00), Quick Scan Time (2.00), and Unknown Maximum Count (10000000). It includes explanatory text about background counting and Unknown Count Time Factor.
- Calculate Off-Peak Times Based On Statistics Dialog:** A dialog with input fields for On-Peak Count Rate (1324), Off-Peak Count Rate (23), On-Peak Count Time (240), and Off-Peak Count Time (31.6323). It features a formula $t_B = t_P \sqrt{\frac{I_B}{I_P}}$ and an 'Apply' button.
- Beam Averages and Nominal Beam:** Fields for 'Beam Averages' (1) and 'Nominal Beam (nA)' (20.0000).
- Visual Elements:** A bar chart showing calculated times for elements like Sr, Al, U, Pb, Er, Dy, Gd, Sm, Nd, Pr, Ce, La, Y, Tl.

Balance spectrometer acquisition load by distributing acquisition time between different elements and individual spectrometers.

12. New Move Spectrometer/Stage Window Controls

- Periodic table element selection with over voltage and spectrometer position data information feedback.
- ROM peaking button for quick and easy tuning.
- PHA tuning button for quick and easy adjustment.



Select, adjust and peak element PHA and spectrometer position quickly with visual confirmation and automatic recording of all data to your user database.

13. New Quick Standard Acquisition Options

- Acquire all elements in all standards (for critical cross checking of secondary standards).
- Acquire normal “quick” standards (automatically acquire assigned elements only) .
- Acquire “smart quick” standards (automatically acquire assigned elements plus major elements in secondary standards).

Acquisition Options

Click Element Row to Edit Acquisition Options

Channel	Element	Spectro	Crystal	Order	Std Bgd	Unk Bgd	Peaking	Nth Point	Nth Interval
1	na ka		1 TAP		1 MAN	MAN	No	No	1C
2	si ka		2 LPET		1 MAN	MAN	No	No	1C
3	k ka		3 LPET		1 Off Peak	Off Peak	No	No	1C
4	al ka		4 TAP		1 Off Peak	MAN	No	No	1C
5	mg ka		1 TAP		2 MAN	MAN	No	No	1C
6	fe ka		5 LIF		1 MAN	MAN	No	No	1C
7	ca ka		2 LPET		2 MAN	MAN	No	No	1C
8	s ka		2 LPET		3 Off Peak	Off Peak	No	No	1C
9	cl ka		3 LPET		2 Off Peak	Off Peak	No	No	1C

Acquisition Order

Channel Number

Ascending Angstroms

Descending Angstroms

User Defined Order Number

Spectrometer Motion

Asynchronous

Synchronous

Quick Standard Acquisition Modes

Only Assigned Elements

Assigned or Major Elements > wt%

Nth Point Off-Peak Background Options

Use Nth Point Acquisition For Off-Peaks

Use Nth Point Monitor Element Intensity

Element Intensity To Monitor

Percent Change Intensity

On Peak Time Fraction

Automation Error Reporting

E-mail Notification of Status and Errors

E-Mail Address to Report Automation Status and Errors

EDS Acquisition [EDS Demonstration]

Acquire No EDS Spectra [Help](#)

Acquire EDS Spectrum Intensities

Note: EDS is not available with "combined" conditions!

EDS Unknown Count Factor

Maximum Energy (keV) Get Set

Pulse Throughput (kcps)

Use Preset Time (in EDS application)

Use Specified Count Time

CL Acquisition

Acquire No CL Spectra

Acquire CL Spectrum Intensities

CL Count Time

CL Unknown Count Factor

Dark Spectra Count Time Fraction

Stage/Spec BackLash (only with automation)

BackLash Correction on Standards

BackLash Correction on Unknowns

BackLash Correction on Wavescans

BackLash Correction on Spectrometers

Miscellaneous Options

Return to On Peaks After Acquisition

Do Not Set Conditions During Acquisition

Blank Beam After Move and Acquisitions

Measure Absorbed Current On Samples

Measure Beam On Sample Acquisitions

Measure Beam Current On Wavescans

Measure Beam Current On Wavescans Nth Point Beam Measurement

Beam Off During Spectrometer Motion

Use Alternating On And Off Peak Acquire

Load Standard Data From File Setup

Do Not Display Standard Images

Use Last Unknown As Wavescan Setup

Use Unknown Count Time For Interf. Std

Use Decontamination/Incubation Delay

Decontamination/Incubation Delay

Auto-Focus Threshold (JEOL only)

Use Only Digitized Standard Positions

Use Current Instrument Conditions Always

Use Automated PHA Control

Use MCA PHA Acquisition Hardware

Automatic Analysis and Output Modes

Use Automatic Analysis After Acquisition

Export Weight Percents To Excel Link

Export Raw K-Ratios To Excel Link

Export Counts/Sec To Excel Link

Export Raw Counts (i?) To Excel Link

Automated Image Acquisition

Acquire Automated Images on Standards

Acquire Automated Images on Unknowns

Acquire Automated Images on Wavescans

Before After Both

Use Sample Mag KeV for Automated Imaging

Change All To Off-Peak

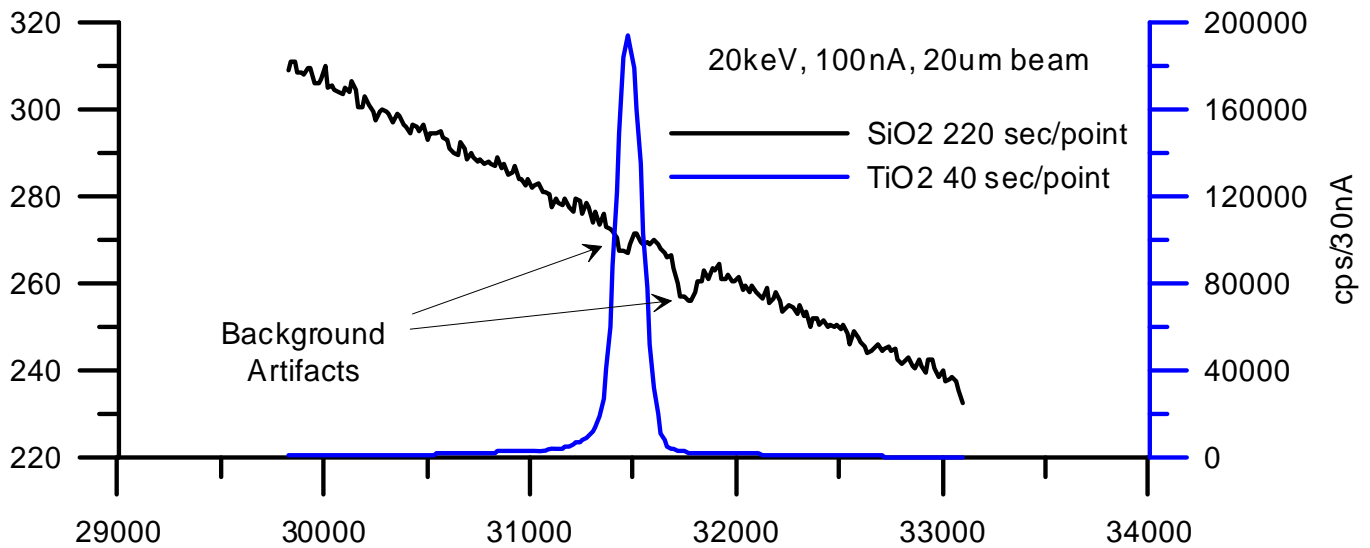
Change All To MAN

Acquire full standardizations for maximum flexibility or just the elements actually assigned as standards or interferences standards (including MAN background curves).

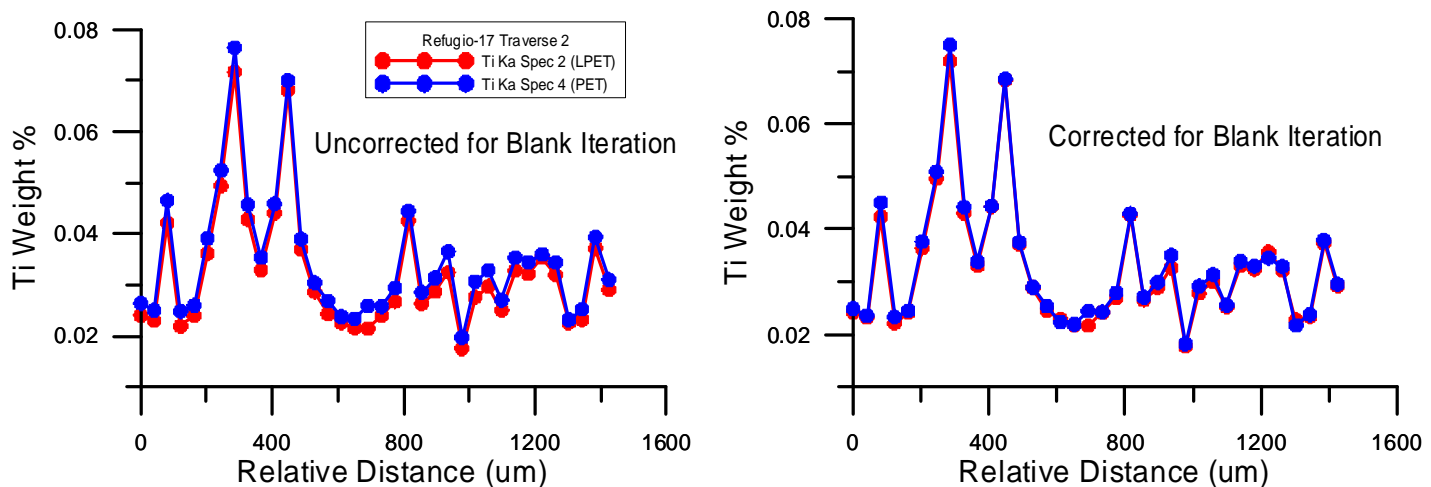
Use the new “smart” option to automatically acquire assigned elements plus any elements higher than a user defined concentration. Use additional intensities to re-assign standards at any time- all in a single portable user relational database.

14.A New Improved Accuracy Correction For Trace Elements

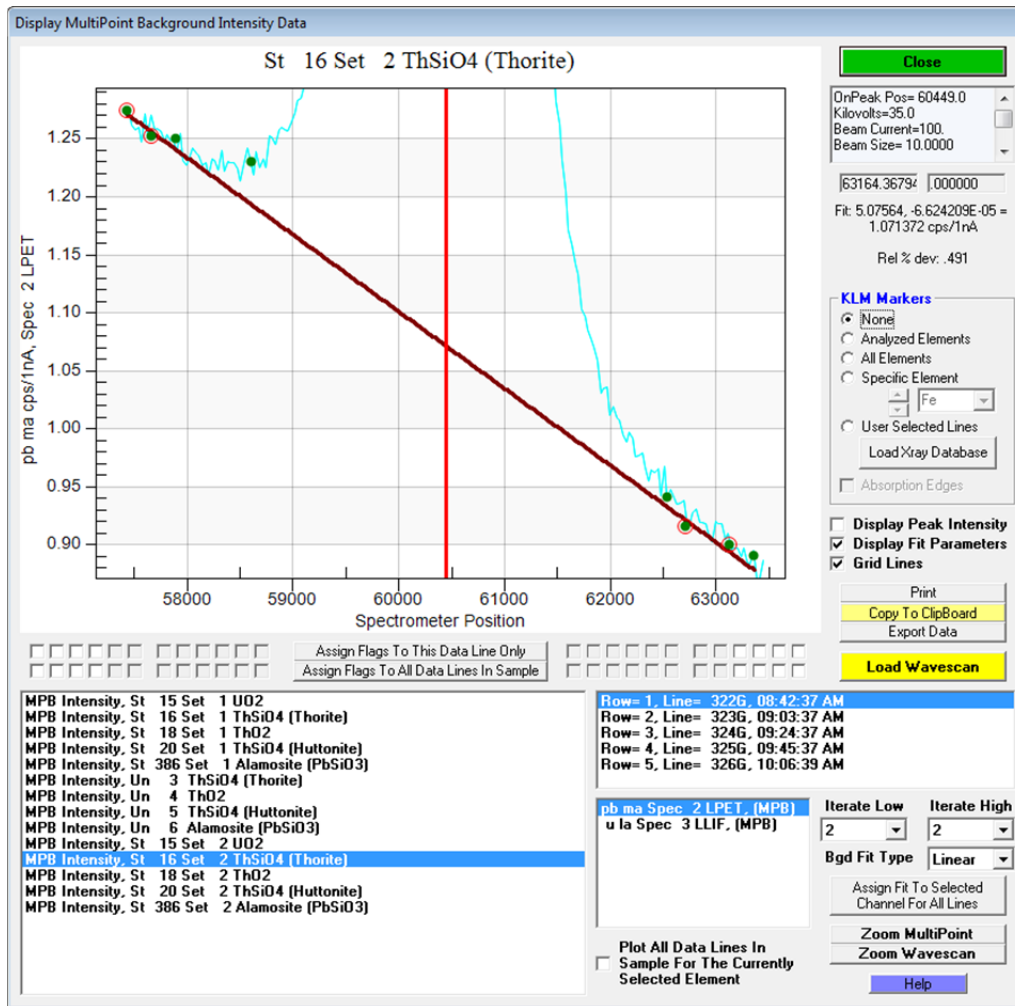
- Modern EPMA instruments equipped with low noise detectors, counting electronics and large area analyzing crystals can now routinely achieve sensitivities for most elements in the 10 to 100 PPM levels. However, because of various sample and instrumental artifacts in the x-ray continuum, absolute accuracy is more often the limiting factor for trace element quantification.



- A new “blank” correction developed for Probe for EPMA can be automatically applied to x-ray intensities during the matrix iteration process to correct for these systematic accuracy errors that are measurable at levels up to 50 PPM depending on particular spectrometer and crystal configurations.
- Trace concentration accuracies even at 500 PPM levels are improved significantly as the following graph demonstrates:



16. New Multi-Point Background Feature



- In materials where the composition is variable or several different phases are present, it is usually necessary to perform many time-consuming spectrometer scans at sufficiently high precision levels to avoid unknown interferences and other continuum artifacts such as “holes” in the background as described by Self, Wark and other workers.
- To handle these situations automatically and accurately, Probe Software has developed new acquisition and calculation methods collectively known as the “multi-point background” feature. This multi-point background acquisition will automatically acquire a number of off-peak intensities distributed on each side of the analytical peak so that at least a few of the background measurements will be unaffected by the unexpected presence of other elements or continuum artifacts that could lead to systematic errors. The background intensity is calculated automatically by iteratively looping on the measured multi-point intensities and optimizing on the best fit of the relative lowest variances until the specified number of valid background positions is reached.
- Above is a screen shot showing this multi-point background calculation for one data point. As can be seen, the off-peak positions closer to the Pb Ma analytical line were interfered by the tails of the Th Mz1 and Mz2 lines (there is no Pb in this ThSiO4 sample). However, the program correctly iterates the multi-point off-peak backgrounds to find the best fit to remove the problematic background measurements automatically.

Contact: John Donovan, donovan@probesoftware.com or call (541) 343-3400 for more information.
02-14-2016